## Role of Correlation on Charge Carrier Transport in Organic M olecular Sem iconductors

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## Abstract

We have investigated the charge carrier transport in organic molecular sem iconductors. It has been found that mobility is a function of electric eld and temperature due to hopping conduction. Several theoretical models for charge transport in disordered solids have been debated over the role of spatial and energetic correlation in these systems and such correlations have been recently shown to explain the universal electric eld dependence of mobility. We have compared and evaluated the applicability of diment theoretically proposed models using very simple experimental results and based on our extensive analysis, we have found that correlation is important to explain the electrical transport in these systems.

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Recently, considerable debate [1, 2, 3] is going on regarding the charge carrier transport in organic m olecular sem iconductors (OMS), which belong to wide class of material, known as disordered organic molecular solids (DOMS), because of two reasons: rst, their application in display devices and second, the fundamental understanding of charge transport in these materials. There are several distinguishing features of these solids, (i) they are composed of organic molecular coupling is strong; (ii) the absence of long range order in these disordered materials lead to the localization of the electronic wave function and the formation of a broad G aussian density of states (GDOS) and the most important one is (iii) the carrier mobility exhibits a nearly universal Poole-Frenkel(PF) behavior[2]

$$(F;T) = (0;T) \exp (T)^{p} \overline{F}$$
 (1)

where (0;T) and (T) are temperature dependent quantities, known as the zero eld mobility and the eld activation of the mobility, respectively. In DOM S, hopping among them olecular sites having comparable energies, describes the transport of charge carriers through the GDOS of highest occupied molecular orbital (HOMO) and/or lowest unoccupied molecular orbital (LUMO). Recently, several theoretical [1, 2, 3] models for charge transport in disordered solids have been debated over the role of spatial and energetic correlation in these system s and such correlations have been recently shown to explain the universal electric eld dependence (Eq.1) of mobility. In this paper, we have exam ined the charge carrier transport in OMS and we show for the rst time, by means of simple experiments that correlation is important in explaining charge carrier transport in OMS.

For our study we have chosen m etalphthalocyanine (M ePc) based thin Im s as the organic solids because beside their potential application for plastic based optoelectronic devices and transistor, these m aterials are (i) the most chem ically and them ally stable compounds, (ii) suitable for organic single layer structures with di erent m etal electrodes without e ecting the interface properties and nally (iii) reproducibility of experimental data for devices with M ePc as organic layers, which is a major problem with most other organic solids due to their degradation with time and the interaction of organic materials with the di erent m etal electrodes, notablly with low work function m etal electrodes. M ePc based organic single layer devices were prepared by sandwiching a thin organic layer of M ePc between indium tin oxide (IT 0) coated glass substrate and them ally evaporated m etal electrodes, using vacuum

deposition technique. We report the experim ental investigation on charge carrier transport in hole only devices based on m etal/M eP c/m etal structures. W ork functions of IT O and Cu are 4.75eV and 4.6eV, respectively, very close to the ionization potential (4.8eV) of M ePc[4], hence the IIO /M eP c and IIO /Cu interfaces behave an 0 hm ic contact. The tem perature dependent current-voltage (J-V) characteristics were studied for IT 0 /M eP c/A 1 structures with di erent MePc layers, choosing ITO as the anode. By properly choosing contacting m etals (C u and A l), current in jection and transport due to holes have been investigated. Here we have chosen copper phthallocyanine (CuPc) and zinc phthalocyanine (ZnPc) as the MePc for these investigations. High purity, sublim ated CuPc and ZnPc have been procured from A klrich Chemical Co. CuPc (ZnPc) was evaporated on ITO coated glass substrates from a resistively heated tungsten boat. Each layer was deposited in a vacuum chamber at a rate of 5-10A /s. Thickness of the resulting organic In swas between 25 to 500nm. The metals for the top electrode (Au, Cu and Al) were placed in a resistively heated tungsten lament and evaporated in a vacuum chamber. All evaporations were done at a base pressure of 2  $10^{-6}$ Torr. We have measured the J-V characteristics by continuously varying the bias and also by interrupting the bias between each voltage step and in both cases, we have found same results. The J-V characteristics for the ITO /M eP c/m etal structures with di erent thickness of M eP c layers were reproducible at all tem peratures and showed no hysteresis.

Fig.1 shows the J-V characteristics of ITO/CuPc/Al and ITO/CuPc/Cu at room temperature. The experiment consisted of two steps. First: the current due to hole injection from ITO was measured by supplying it to positive bias (forward bias) and second: the current due to hole injection from Cu and Al was measured by reversing the polarity of the bias voltage, i.e., biasing Al and Cu electrodes positively (reverse bias). It is clear from Fig.1 that J-V characteristics in case of ITO/CuPc/Cu display alm ost symmetric behavior in both cases (hole injection either from ITO, or from Cu electrodes). This is because in both cases there is small energy barriers of 0.05eV in case of ITO/M eP c and 0.2eV in case of Cu/M eP c interface, giving rise to space charge limited (SCL) bulk current when either ITO or Cu is positively biased. It has been shown [5, 6], for Schottky energy barrier (SEB) less than about 0.3-0.4eV, the current ow is due to SCL [7, 8, 9]. But, in case of ITO/M eP c/Al devices, J-V characteristics display diode like asymmetric behavior. Current density increases by alm ost ve orders of magnitude by reversing the polarity of the bias.

In several cases [4, 7, 9], the current transport mechanism has been explained in non-

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crystalline organic sem iconductor by extending the space charge limited current (SCLC) and trap charge limited current (TCLC) transport models in crystalline sem iconductors [10, 11] and J-V characteristics beyond 0 hm 's law was given by

$$J / \frac{V^{m+1}}{d^{2m+1}}$$
 (2)

where m = 1 in case of SCLC and  $m = T_0 = T$  in case of TCLC,  $T_0$  is the characteristic tem perature of the traps and d is the thickness of the sam ple. W e found in all our single layer devices with di erent electrodes (Al, Cu) and di erent MePcs (CuPc, ZnPc), J-V characteristics follow SCLC like behavior  $(J / V^2)$  at low bias in forward bias condition, i.e. when ITO electrode is positively biased. It is appealing to attribute this behavior to SCLC, but as the bias increases the slope (m + 1) in log-log plot of J vs. V curves increases gradually from m = 1. This deviation can not be explained [9] as due to the presence of traps, because SCLC would not apply for low bias either. There are valid objections [9, 12, 13] against the use of transport theory (SCLC and TCLC) for crystalline systems in case of disordered systems, like OMS.Failure of the proposed SCLC and/or TCLC for crystalline insulators[10, 11] in our devices and several other cases[9, 12, 13] can be argued for following reasons. (i) As mentioned already, OMS does not have valence and conduction bands (as in case of crystalline sem iconductor) due to lack of long range ordering in these materials. A distinguishing feature of molecular and polymeric organic sem iconductors is that they are molecular glasses, composed of molecular entities held together by weak van der W alls interactions. They are characterized with HOMO and LUMO bands with GDOS. The tail states in HOMO/LUMO generally acts as traps and get led with an application of bias due to the penetration of quasi-Ferm i level inside the GDOS. (ii) SCLC and/or TCLC theories are applicable for crystalline systems and assume constant mobility. In case of molecular sem iconductors, mobility is being a ected by the disorders and the transport takes place by electrons hopping through M eP c m olecular sites having com parable energies within the GDOS resulting bulk limited behavior in the current conduction. In this case, mobility becomes a function of electric eld due to the distribution in energy of hopping sites. Essentially, the electric eld assists carriers in overcoming the potential barrier between sites with dierent energies. It has been found that the mobility of carriers in thin lms of poly-phenylene vinylene (PPV) [9, 13] and tris, 8-hydroxyquinoline alum inum (Alq3) [14] over wide range of elds can be described according to universally observed PF relation (Eq.1).

(iii) In several reports [7, 8, 9], thickness dependence of current has been used to corroborate the SCLC theory. But it has been shown [12] that current transport based on eld dependent m obility due to hopping of charge carriers can account for sim ilar thickness dependence. It is also possible to account for J /  $V^m$  relation without unphysical assumptions of TCLC theory.

The tem perature dependence of electrical conductivity associated with the hopping motion in non-crystalline solids is explained by

$$(T) = {}_{0} \exp \left(\frac{T_{0}}{T}\right)$$
(3)

where  $_0$  is the tem perature independent resistivity and  $T_0$  is the characteristic tem perature,  $=\frac{n+1}{n+D+1}$  is known as hopping exponent, D is the dimension, n is the exponent in the density of states q(E) in the vicinity of the Fermi energy  $E_F$ , which behaves like q(E) $E_{\rm F}$  )<sup>n</sup>. For an energy independent density of states (n = 0), the values are 1/4 (王 and 1/3 in 3-D and 2-D, respectively. This is the Mott-Davis variable range hopping [15] mechanism. Shklovskii and E fros [16] have shown that C oulomb interaction leads to a gap in g(E) around  $E_F$  and n = 1 in 2-D, i.e., g(E) ( $E_F$ ) and n = 2 in 3-D, i.e.,  $\mathrm{E}_{\,\mathrm{F}}\,\,\mathfrak{J}^2$  . Hence electron-electron interaction change the variable range hopping (È qΈ) exponent to  $=\frac{1}{2}$  in both 2-D and 3-D. Tem perature dependence of resistivity (T) over wide range of tem perature for two thicknesses of CuPC is shown in Fig2. We have tried to t the resistivity data with di erent values. Fig.2 shows the ln () vs  $1=T^{1-4}$  and also the ln( ) vs  $1{=}T^{1{=}2}$  plot. It is observed that the 100nm structure shows better  $\;$  tting with the 1=T<sup>1=4</sup> plot, whereas the 400nm structure shows better thing with the 1=T<sup>1=2</sup> plot. For an improvement upon this eyeball approach, we adopt the method used by Hill[17]. He introduces the quantity a = d[n()]=d(1=T) as the tem perature dependent activation energy for variable range hopping conduction. Eq.3 can be expressed as

$$\ln \frac{d[\ln (T)]}{d(1=T)}^{!} = \ln (T_{0}) + (1) \ln T$$
(4)

One can determ ine from <sub>a</sub> vs T plot in log-log scale. We have plotted according to Eq.4, the straight line t gives the value of = 1=5 for 100nm (Fig.3) and = 3=5 for 400nm (Fig.3) CuPc layers. Since the value 1/5 is closer to 1/4 and 3/5 is closer to 1/2, the straight line t in  $\frac{1}{T}$  plots shows better tting with =  $\frac{1}{4}$  for 100nm and with =  $\frac{1}{2}$ 

for 400nm structures. Hence, it seems hopping mechanism may be in lower and higher thickness of CuPc layers. Moreover, hopping mechanism may be altogether di erent from either Mott-Davis[15] or E fros-Shklovskii[16] in OMS and the pre-exponential factor( $_0$ ) may depend on temperature. Fig.4 shows the temperature dependent resistivity at various electric elds for ITO/CuPc(100nm)/Al structure. The linear dependence in ln (T) vs  $1=T^{1=4}$  upto 30K is observed. The electric eld dependence on resistivity is studied for the  $_0$  at di erent electric elds. The straight line t of ln ( $_0$ ) vs F<sup>1=2</sup> plot, shown as inset in Fig.4, signi es the universally observed Poole-Frenkle relation (ln () / F<sup>1=2</sup>) concerning charge carrier transport in OMS.

To t the experimental results, we have modi ed SCLC transport theory by simultaneously solving the current density equation and Poission's equation with electric eld dependent mobility (PF relation i.e. Eq.1)

$$J(x) = p(x)e [F(x);T]F(x)$$
 (5)

$$-\frac{\mathrm{dF}(\mathbf{x})}{\mathrm{e}\,\mathrm{dx}} = \mathbf{p}(\mathbf{x}) \tag{6}$$

where p(x) is the hole density at position x and (F;T) is the hole mobility in MePc. Taking the boundary conditions (i) ohm is contacts at ITO/MePc interface(at x = 0) i.e. electric eld vanishes(F = 0) at x = 0, and (ii) hole density is equivalent with the density of states(N<sub>v</sub>) in HOMO of MePc, i.e.  $p(0) = N_v = 10^{19}$  cm<sup>-3</sup>, at x = 0. The excellent agreement between simulated J(V) results and experimental J-V characteristics for three dient single layer deices based on CuPc and ZnPc over wide range of temperature is shown in Fig.5. Following are the observations, (i) the simulated result follows J / V<sup>m</sup> dependence, (ii) m is 2 at low electric elds and increases gradually from m = 2 at high electric elds and (iii) the value of m increases with temperature. Hence, the experimental data presented in Fig.2, Fig.3, Fig.4 and Fig.5 alongwith simulation results establish the carrier transport process, which is therm ally activated hopping with electric eld dependent carrier m obility.

There are three most in portant models for the explanation of particular temperature dependence of zero eld mobility ((0;T)) and the eld activation energy ((T)), appearing in universally observed PF relation (Eq.4.1) about charge carrier mobility. Those are, (a) G ill's

phenom enologicalm odel[18] (b) Uncorrelated G aussian disorderm odel[1] and (c) C orrelated G aussian disorderm odel[3]. G ill attempted to describe[18] the experim ental data with the following empirical form of charge carrier mobility

$$(F;T) = _{0} \exp \frac{B}{k_{\rm B}T} \exp \frac{B}{k_{\rm B}} \frac{1}{T} \frac{1}{T_{0}} \frac{P}{F}$$
(7)

where  $_0$  is the tem perature independent m obility, is the zero- eld activation energy, B is a parameter, and T<sub>0</sub> is the characteristic tem perature of the material. In this case, (0;T) and (0;T) have 1=T dependence. C on paring this with the PF relation (Eq.1), (0;T) and (0;T) on the emperated as

(0;T) can be expressed as

$$(0;T) = _{0} \exp \frac{1}{k_{\rm B}T} ; (T) = \frac{B}{k_{\rm B}} \frac{1}{T} \frac{1}{T_{0}}$$
(8)

The (0;T) and (T) at dimensional temperatures, determined from theoretical the experimental J-V characteristics (shown in Fig.5) are plotted in Fig.6 according to Eq.8. From  $\ln [((0;T))] vs 1=T$  plot, the values of temperature independent mobility  $_{0}$  and the activation energy are calculated. The value of the constant B and the characteristics tem – perature  $T_{0}$  are calculated from the (T) vs 1=T plot and given in Table-I.

Bassler and co-workers proposed [1] the uncorrelated Gaussian disorder model (UGDM) and provided support to PF behavior of mobility using M onte Carlo simulation. The UGDM describes the carrier transport as a biased random walk among the hopping sites with Gaussian-distributed random site energies. UGDM lead to following form of carrier mobility

$$(F;T) = {}_{0} \exp \frac{2}{3} {}^{2} + C {}^{2} {}^{2} \frac{p}{F}$$
(9)

where  $^{P}$  = =k<sub>B</sub>T,C & <sup>P</sup> are constants, is the G aussian width of the hopping sites distribution. In this case, (0;T) and (0;T) have 1=T<sup>2</sup> dependence, instead of 1=T dependence as in case of G ill's empirical relation. C om paring this with the PF relation (Eq.1), (0;T) and (0;T) can be expressed as

$$(0;T) = _{0} \exp \frac{2}{3} ^{2}; (T) = C^{2} ^{2}$$
 (10)

Fig.7 shows the temperature dependence of the (0;T) and (T) according to UGDM and the apparent linear dependence of  $\ln (0)$  on  $1=T^2$  and (T) on  $1=T^2$  can be described by

Eq.10. Values of tem perature independent mobility  $_0$ , width of the energy spread, and the constants C and are determined from the ln (0;T) vs.  $1=T^2$  and (T) vs.  $1=T^2$ plots, and given in Table II. Although UGDM explains some features of experimental data and provides support for PF behavior of carrier m obility, several discrepancies em erge with uncorrelated description of Gaussian disorder model, which will be discussed later. The most important criticism against UGDM is its' inability to reproduce the PF behavior over wider range of electric eld. Garstein and Conwell [0] rst showed that a spatially correlated potential is required for the description of PF behavior of m obility for wider range of electric eld. D unlop and co-w orkers?] have shown that the interaction of charge carriers with perm anent dipoles located on either dopant or host m olecules give rise to PF behavior of m obility. E sentially, this correlated G aussian disorder m odel (CGDM) is based on long-range correlation [3] between charge carriers and the molecular electric dipole, resulting random potential energy landscape with long-range spatial correlations, < U (0)U (r) > 2a=r, where a is the minim al charge-dipole separation or the lattice constant of the molecular solid and is the width of the G aussian distribution and can be given by  $= 2.35 \text{ep} = a^2$ , where p is the dipole moment of the molecule. In this case, carrier mobility can be given by

$$(F;T) = _{0} \exp \frac{3}{5}^{2} + A^{3=2} \qquad \frac{\# s}{=} \qquad (11)$$

where A and are parameters of the model. characterizes the geometrical disorder. In this case, (0;T) has a 1=T<sup>2</sup> dependence (sam e as in UGDM) but (T) has a 1=T<sup>3=2</sup> dependence. Comparing this with the PF relation (Eq.1), (0;T) and (0;T) can be expressed as

$$(0;T) = {}_{0} \exp \left(\frac{3}{5}^{2}\right)^{2}; (T) = C_{0}^{3=2} \qquad \frac{r}{\underline{ea}}$$
(12)

Fig.8 shows the tem perature dependence of (0;T) and (T) according to CGDM, described by Eq.12. Values of the parameters  $_0$ , , a and are determined from the straight line plots of ln (0;T) vs.  $1=T^2$  (shown in Fig.8) and (T) vs.  $1=T^{3=2}$  (shown in Fig.8) and given in Table III.

Though the uncorrelated m odels (G ill's phenom enological relation and UCGM) can describe the experim ental data upto a som e extent, but have certain limitations which are discussed below. There are several conceptual problems with G ill's phenom enological description and the most important are (i) the obtained values of zero eld and tem perature independent m obility ( $_0$ ) are overestim ated by several order of magnitudes and don't m atch with the values obtained by independent measurements, (ii) the empirical G ill's formula lacks theoretical justication and the signicance of dierent parameters (, B and T) are not well understood in the context of the physical properties of the system and (iii) the em – pirical formula for (T) predicts the negative eld dependence for T T<sub>0</sub>, which deviates from the universal feature (PF) of carrier transport in these materials.

M ain feature of UGDM is the non-A mehenious behavior of the tem perature dependence of m obility, which is the consequence of hopping conduction in GDOS.But, there are several discrepancies in this description and those are (i) thing is not as good as in case of CGDM, (ii) the intercept of (T) vs.  $1/T^2$  (shown in Fig.7) gives positive value, but according to UGDM relation Eq.10, it should be negative, which is a fundam ental problem with UGDM, (iii) it has been observed that there is no speci c trend in the values of C, which is scaling parameter in the model and cannot be linked to a physical parameter of the system and (iv) its' inability to reproduce the PF behavior (which is a universal feature of charge carrier transport in these materials.) over wider range of electric eld[9].

Here, we compare our experimental data with the uncorrelated (UGDM) and correlated (CGDM) theoretical models proposing the stretched exponential electric eld dependence of . As already mentioned, at every temperature, (0;T) and (T) are obtained from the experimental data presented in Fig.5, using the numerical workout and plotted in Fig.8 which shows the temperature dependence of (0;T) and (T) according to CGDM, described by Eq.12. Following observations have been made regarding the CGDM description of the experimental data, (i) linear dependence of  $\ln (0;T)$  on  $1=T^2$  and (T) on  $1=T^{3=2}$  is evident in Fig.8 and straight line t is excellent and better than that in UGDM, (ii) for all sam ples the intercept of (T) vs.  $1=T^{3=2}$  gives negative values, according to CGDM (Eq.12), (iii) the experimental value of are 1.2 in CuP c and 1.4 in ZnP c, which are very close to the predicted value 1.97 [?], (iv) The width of the Gaussian distribution is 100m eV in CuP c and 120m eV in ZnP c and similar values for are commonly observed in other molecular solids, (v) The lattice constant (a) has been found to be 19A in CuP c and 17A in ZnP c, are in excellent agreem ent with the reported [21] experimental values determined by X-R ay di raction.

The UCDM and CGDM share the common feature regarding the temperature dependence of (0;T) due to similar distribution of hopping sites energies, but the temperature

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dependence of eld activation parameter decides critically the importance of spatial correlation and decides the mechanism of carrier transport in organic molecular solids. Though CGDM explains the experimental data successfully, there are some limitations with this model. The positional disorder is not included in the present form of CGDM, but large values of disorder parameters and in NPPDA [], A lq3 [22] and M ePc signify the importance of the positional disorder. In CGDM, it has been shown that long-range interaction between charge carriers and perm anent dipole m om ents of doped m olecules in polym ers and host molecules leads to spatial correlation. However, it has been pointed out by Yu et. al.[23] that the mechanism responsible for PF behavior in di erent conjugated polymers and m olecules cannot be due to only charge-dipole interaction, because PF behavior has been universally observed in several doped and undoped polymers and molecules with or without perm anent dipole moment. Hence, in addition to charge-dipole interaction there may be another mechanism responsible for spatial correlation, which is a fundam ental requirem ent for PF behavior. Yu et. al.[23] have shown using rst principle quantum chem ical calculation that the therm al uctuations in the molecular geometry can lead to spatial correlation. It has been shown that the primary restoring force for the thermal uctuation is steric and interm olecular, which lead to spatially correlated uctuation in the energies of the localized states. Further experimental investigations are in progress to identify the exact origin of spatial correlation in m olecules with and without dipole m om ents.

In sum m ary, we have studied the m echanism of carrier transport in OM S, which belongs to class of disordered m olecular solids, by m eans of sim ple experiments. We have (i) shown that the carriers conducts through hopping; (ii) given evidences for the universal electric eld dependence (ln () /  $p_{\overline{E}}$ ) of carrier m obility and (iii) presented a comparison of the transport properties with uncorrelated and correlated disorder m odel. We have shown that E and T dependence of experimental data can be tted and described within the correlated G aussian disorderm odel, signifying the important role of both energetic and spatial disorder on the carrier transport in these m aterials. The origin of correlation has been discussed. We hope present analysis would lead to further experimental and theoretical investigations focusing the exact origin and role of correlation on transport properties of disordered m olecular solids.

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- Fig.1. Room temperature J-V characteristics for single layer hole only CuPc device with thickness of 200nm. Empty circles represent the data when ITO is positively biased (Forward biased) and empty squares represent the data when ITO is negatively biased (reverse biased). The high recti cation in (a) ITO/CuPc/Al and comparable currents in (b) ITO/CuPc/Cu ensures the condition to achieve the bulk limited current is when ITO is positively biased.
- Fig.2 Tem perature dependent resistivity of CuPc observed in ITO/CuPc/Alstructure with 100nm and 400nm of CuPc layers. Empty symbols are experimental data and solid lines are the straight line t in the log() vs.  $1=T^{1=4}$  in (a) and vs  $1=T^{1=2}$  in (b).
- Fig.3. Tem perature dependent resistivity of CuPc in ITO/CuPc/Alstructure plotted according to Eqn.4 for (a)100nm and (b)400nm CuPc layers. From the straight line t(solid line) to the experimental data(symbols)), the values of = 1=5 for 100nm and = 3=5 for 400nm structures were found out.
- Fig.4. Tem perature dependent conductivity of CuPc observed in ITO/CuPc(100nm)/Al structure. Empty circles are experimental data and solid lines are the straight line t in the log() vs.  $1=T^{1=4}$ . Inset shows the electric eld dependence of tem perature independent resistivity( $_0$ ) at dimensional electric elds and the linear t (solid line) shows the PF dependence of the carrier mobility.
- Fig.5. J-V characteristics of bulk limited current in ITO /M ePc/Alwith ITO anode and Al cathode contacts at di erent tem peratures starting at 320K and then at the interval of 30K. Experim ental data are shown by the empty symbols and solid lines represent the simulated data, for (a) 100nm CuPc layer(device A), (b) 200nm CuPc layer(device B), and (c) 200nm ZnPc layer(device C).
- Fig.6. (a) Tem perature dependence of zero eld m obility (0;T) and (b) the eld activation (T) obtained from the theoretical t to the experim ental data shown in Fig.5, are plotted according to the G ill's phenom enological observation (Eq.8) for devices A, B, and C. The values of the parameters 0, , B, and T<sub>0</sub> are given in Table-I.

- Fig.7. Tem perature dependence of zero eld mobility (0;T) and the eld activation (T) obtained from the theoretical t to the experimental data shown in Fig.5, are plotted according to the UGDM (Eq.10) for devices A, B, and C. The values of the parameters 0, , C and are given in Table-II.
- Fig.8. Temperature dependence of zero eld mobility (0;T) and the eld activation (T) obtained from the theoretical t to the experimental data shown in Fig.5, are plotted according to the CGDM (Eq.12) for devices A, B, and C. The values of the parameters 0, (), and a are given in Table-III.

Table Captions

- Table.I Values of  $_0$ , , B and T $_0$  obtained using G ill's phenom enological relation for three di erent samples.
- Table.II Values of 0, , C and obtained using UGDM for three di erent sam ples.

Table.III Values of  $_0$ , and a using CGDM for three di erent samples.

Table-I

D evice	0			В		Τ <sub>0</sub>
	$in \frac{cm^2}{Vs}$		in eV	in eV (am /V) $^{\frac{1}{2}}$		in K
A	2 <b>:</b> 76	10 <sup>3</sup>	0.44	6:38	10 4	660
В	3 <b>:</b> 78	10 <sup>3</sup>	0.43	5 <b>:</b> 94	10 4	615
С	6:1	10 4	0.46	528	10 4	610

Table-II

D evice	0			С		
	(in cm	<sup>2</sup> =V :sec)	(in m eV )			
A	2:8	10 8	100	6 <b>:</b> 4	10 <sup>5</sup>	-3.1
В	3:0	10 8	95	6 <b>:</b> 9	10 <sup>5</sup>	-3.18
С	1 <b>:</b> 7	10 8	110	4 <b>:</b> 5	10 5	-4.24

Table-III

D evice	0	a	
	(in am <sup>2</sup> =V :sec)	(in m eV )	(in A)
A	2 <b>:</b> 8 10 <sup>8</sup>	106	20
В	3 <b>:</b> 0 10 <sup>8</sup>	100	19
С	1 <b>:</b> 7 10 <sup>8</sup>	118	17

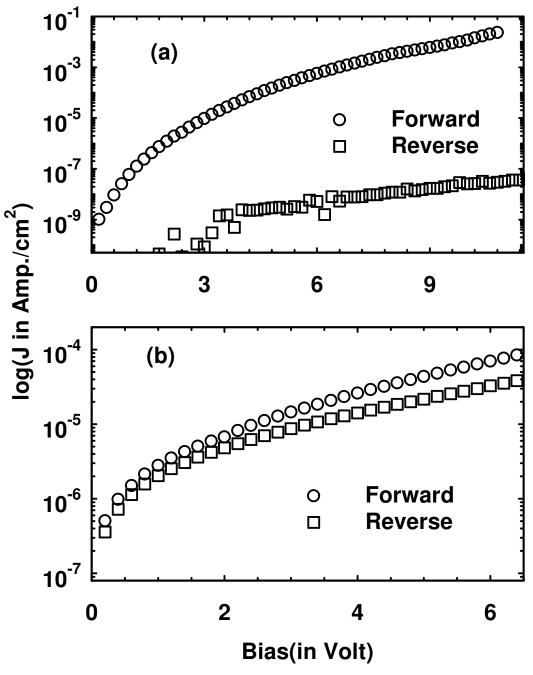


Figure 1

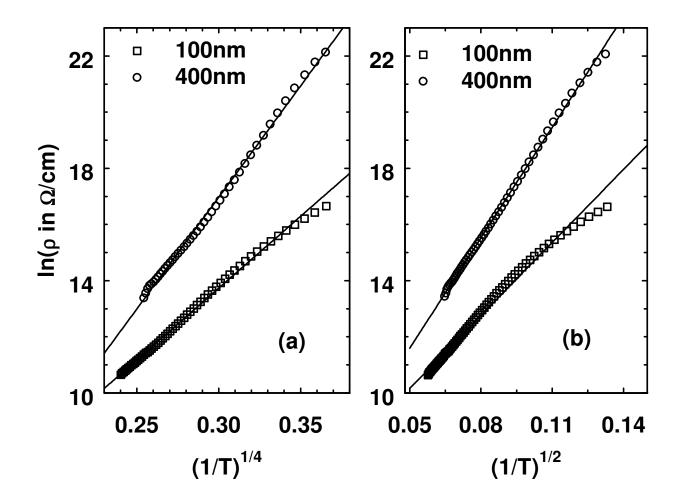


Figure 2

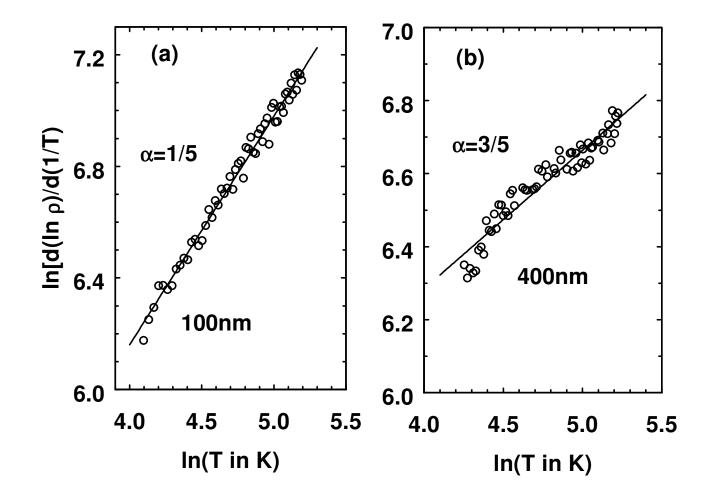


Figure 3

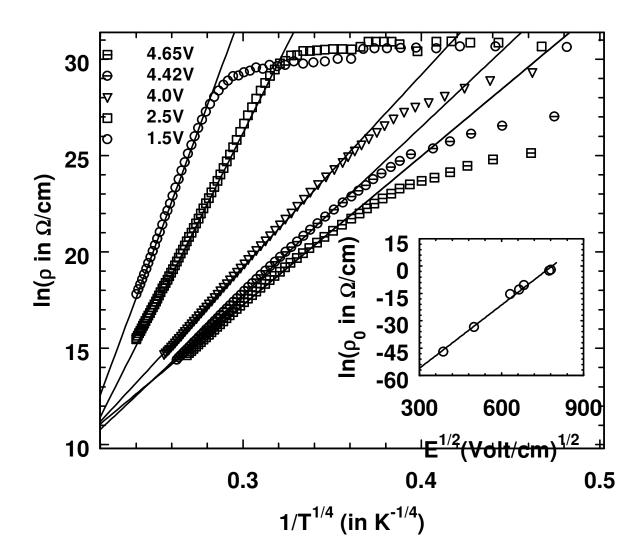


Figure 4

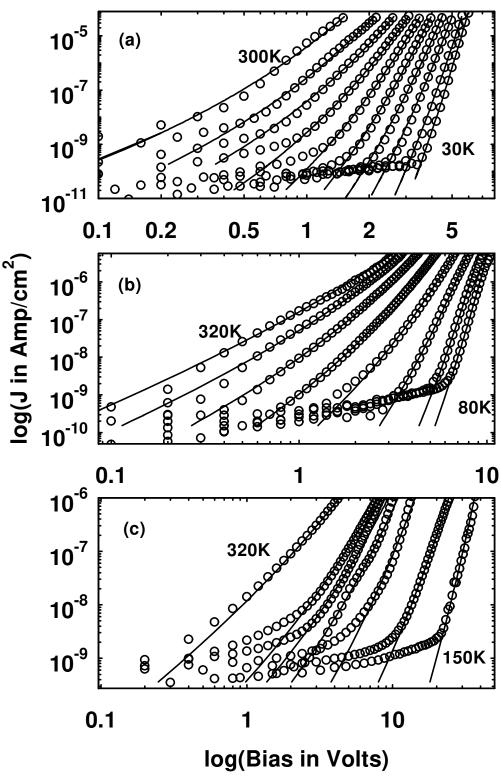
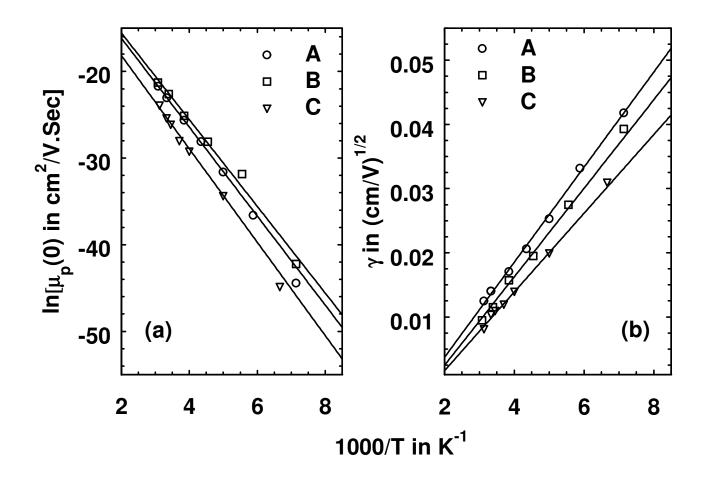


Figure 5



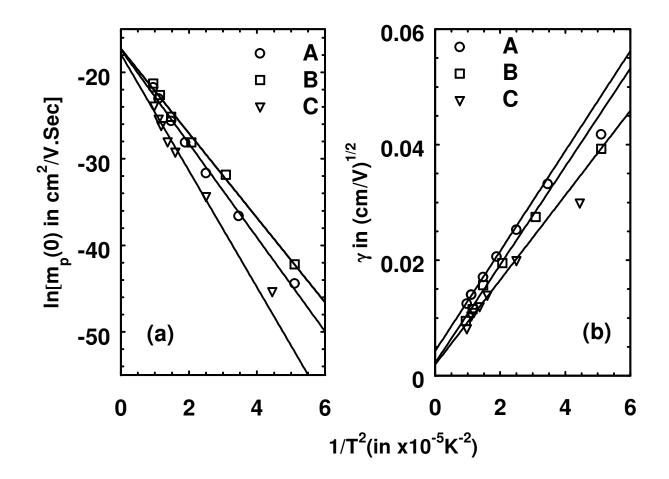


Figure-7

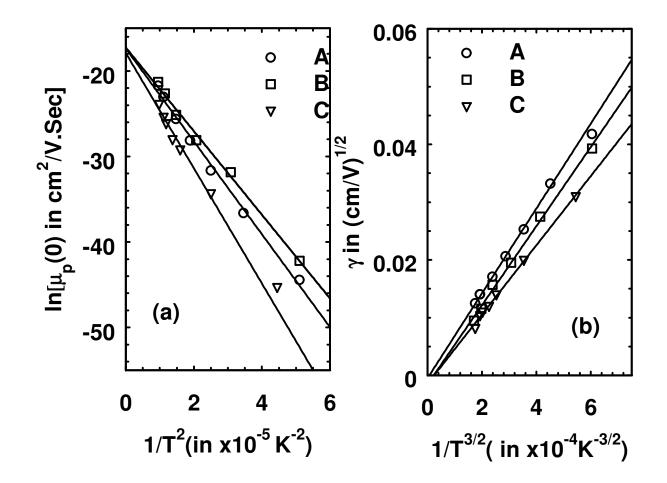


Figure 8